

Characterization of Planar Pixel Sensors for the High-Luminosity Upgrade of the CMS Detector

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Both of them on behalf of the CMS Tracker Group

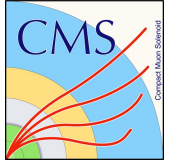


10th International Workshop on Semiconductor Pixel Detectors for
Particles and Imaging
2022-12-13, Santa Fe, USA



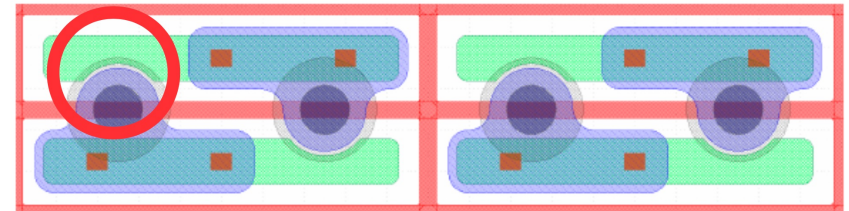
Santa Fe Plaza last night 11 PM

The Planar Sensors – Baseline Design

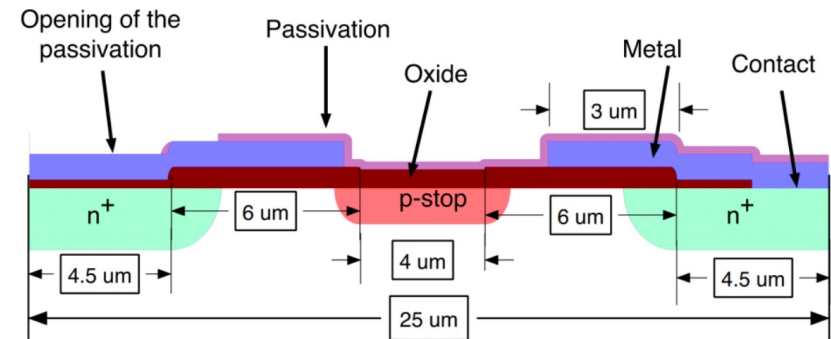


- Hybrid pixel detectors
- Produced by HPK, FBK and LFoundry
- n-in-p planar sensors for all but first barrel layer
- Advantages compared to current n-in-n sensors
 - Single-sided processing
 - Fewer number of production steps
 - Lower production cost
- 150 μm active thickness
 - Higher radiation hardness
 - Lower bias voltage for high efficiency
- 25 x 100 μm^2 pixel pitch
- Parylene coating applied on final modules for spark protection
- No n^+ implant under metal pads of adjacent pixel
 - Reduced crosstalk

“Bitten” n^+ implant



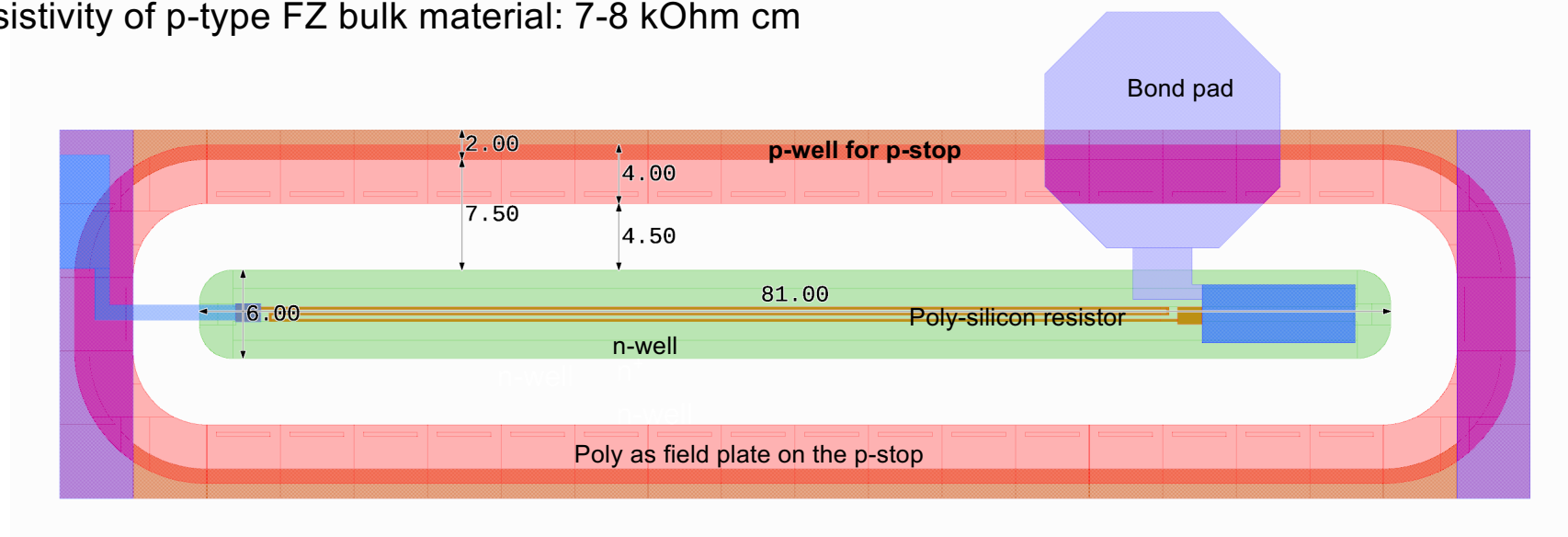
HPK & FBK 6” wafers



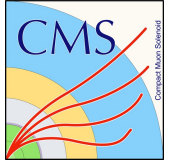
HPK baseline design with p-stop isolation

FBK baseline design has p-spray isolation

- Production of passive sensors on 150 nm CMOS LFoundry process
 - 8" wafers
 - 6 metal layers possible, 4 layers effectively used
 - n-well together with n⁺ used in the pixel body implantation 6 μm x 81 μm
 - p-well with p⁺ used for the p-stop
 - Low resistivity poly-silicon used for field-plates on top of p-stop
 - High resistive poly-silicon layer for bias resistors (square of 0.15 μm side): total resistance ~ 2.7 MΩ
 - Resistivity of p-type FZ bulk material: 7-8 kΩ cm

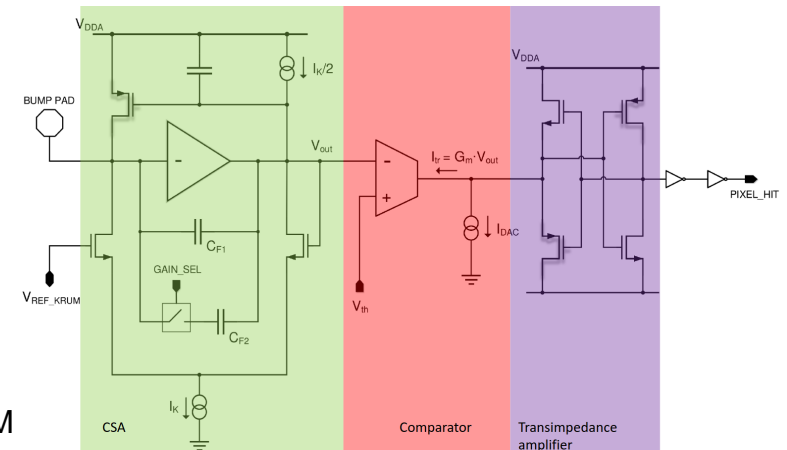
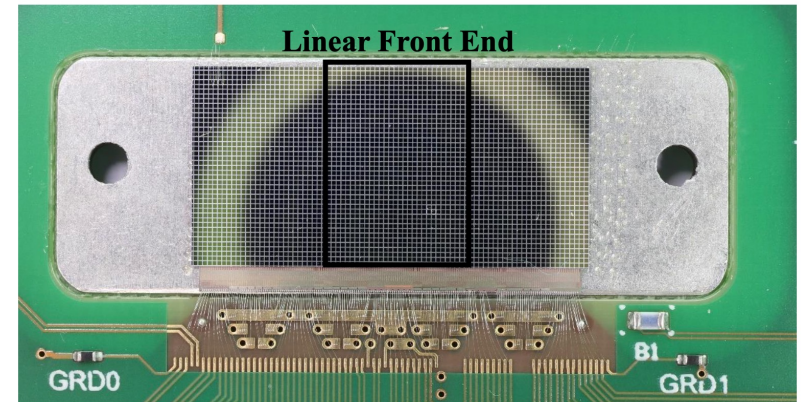


Readout Chip - RD53A



RD53A specs rated for 5MGy

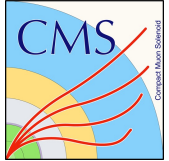
- 400 x 192 pixels
- 50 μm x 50 μm pixel pitch
- TSMC 65 nm CMOS technology
- Serial powering
- Three different analog front-ends
- Linear front-end chosen by CMS
 - 136 columns
 - Adjustable online threshold
 - 4-bit time-over-threshold



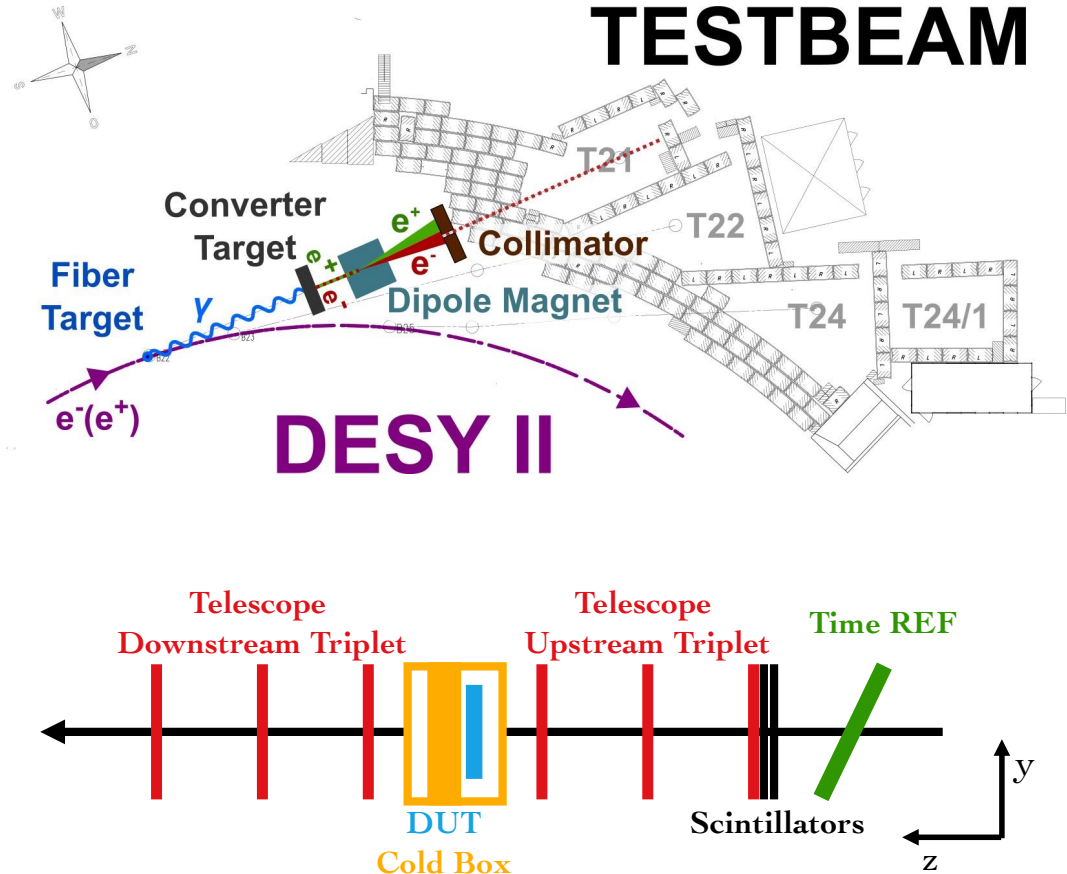
Schematic of the Linear analog front end flavor

All Modules Bump Bonded at IZM

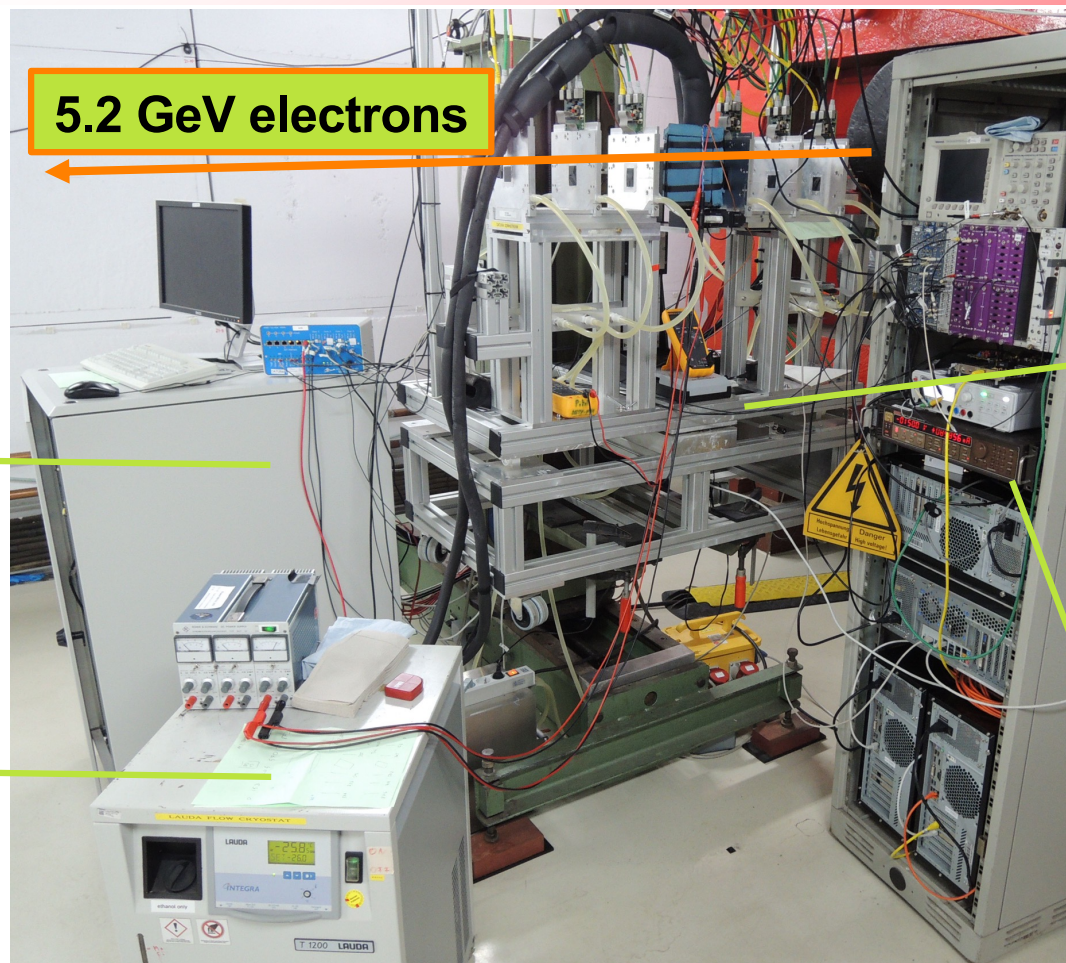
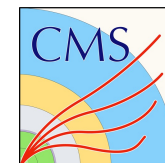
Beam Test Setup at DESY



- Data taken at DESY test-beam 21
- 5.2 or 5.6 GeV electrons
- Scintillator triggers
- EUDET DATURA telescope for tracking
 - 6 MIMOSA-26 planes
 - 115 μ s integration time
- CMS phase-1 module as timing reference
- Device Under Test (DUT) cooled down to -24 deg C (or lower)



Beam Test Setup at DESY



5.2 GeV electrons



Telescope DAQ

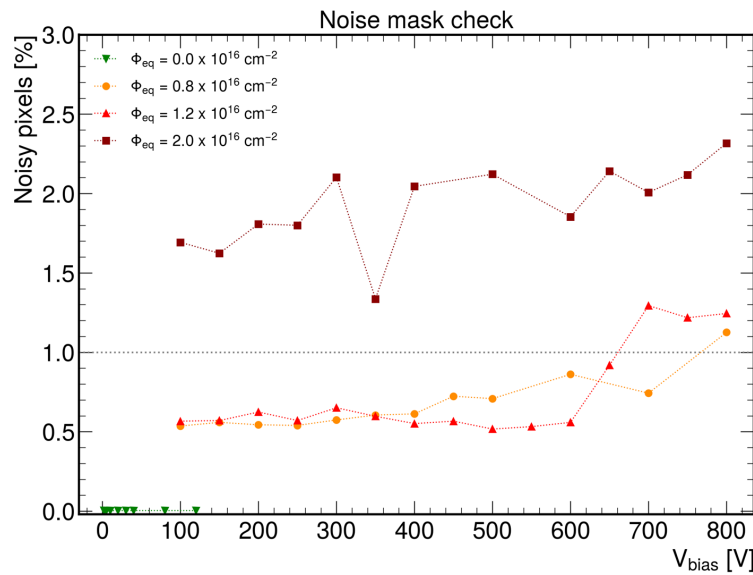
DATURA Telescope

Cooling system

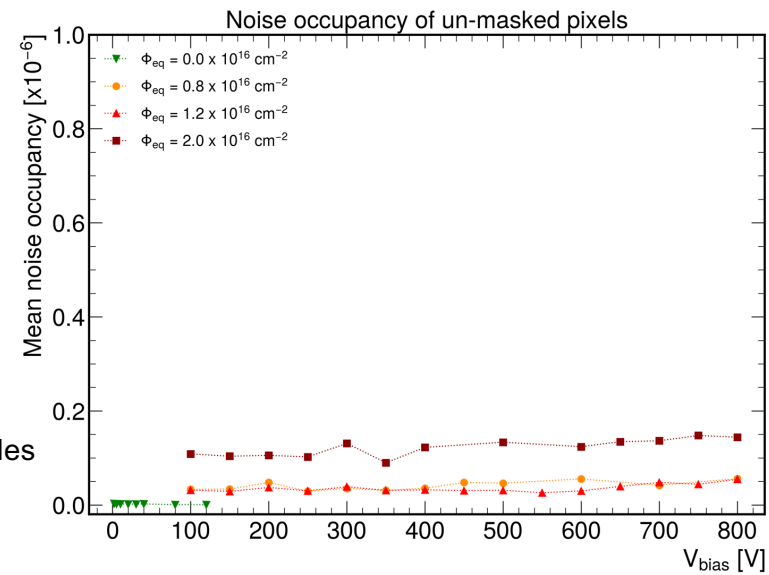
RD53A DAQ, power and trigger systems

- Requirements for the final module
 - Total number of masked pixels < 1%
 - Average noise occupancy of un-masked pixels < 10^{-6}
- Low noise level already achieved with RD53A modules

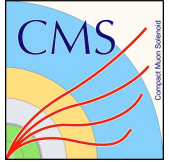
Modules irradiated at KIT 23MeV p beam
 Very high TID: 15 MGy @ $1.0 \times 10^{16} \text{ n}_{\text{eq}} \text{ cm}^{-2}$



HPK single chip modules

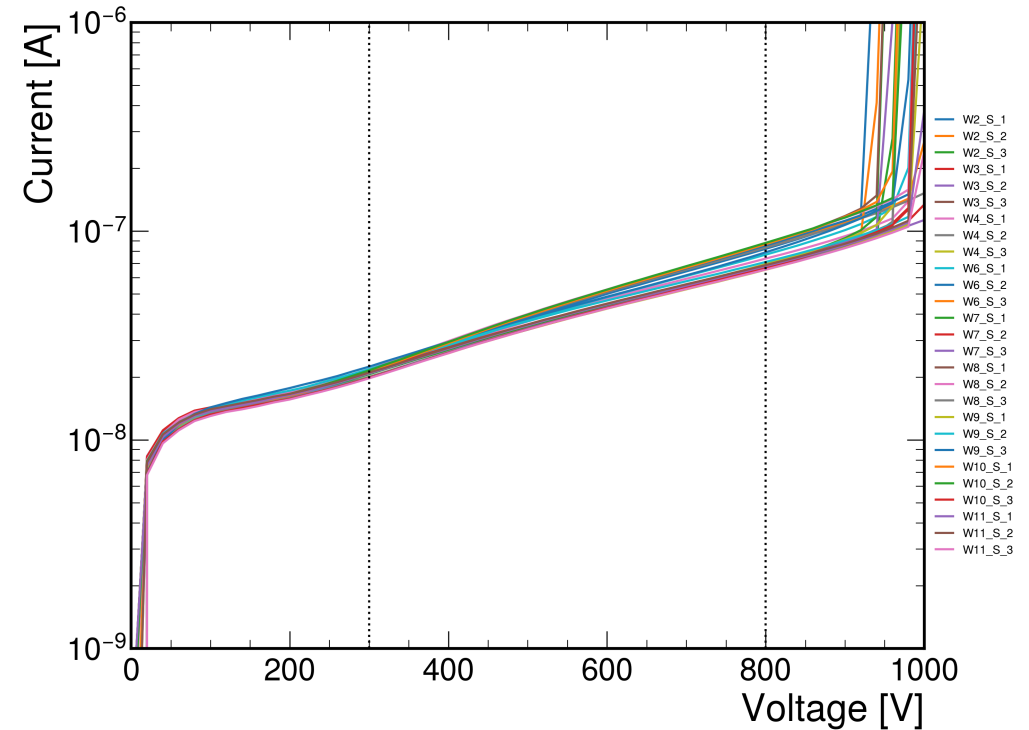


Hit Efficiency and I-V Requirements



$$\epsilon_{hit} = \frac{N_{DUT}}{N_{tracks}}$$

- Non-irradiated:
 - $\epsilon_{hit} > 99\%$
 - at vertical incidence, $V_{bias} = V_{dep.} + 50 \text{ V}$, $+20 \text{ }^\circ\text{C}$
- Irradiated up to $\Phi_{eq} = 0.5 \times 10^{16} \text{ cm}^{-2}$:
 - $\epsilon_{hit} > 99\%$
 - at vertical incidence, $V_{bias} < 800 \text{ V}$, $-20 \text{ }^\circ\text{C}$
- Irradiated up to $\Phi_{eq} = 1.0 \times 10^{16} \text{ cm}^{-2}$:
 - $\epsilon_{hit} > 98\%$
 - at vertical incidence, $V_{bias} < 800 \text{ V}$, $-20 \text{ }^\circ\text{C}$

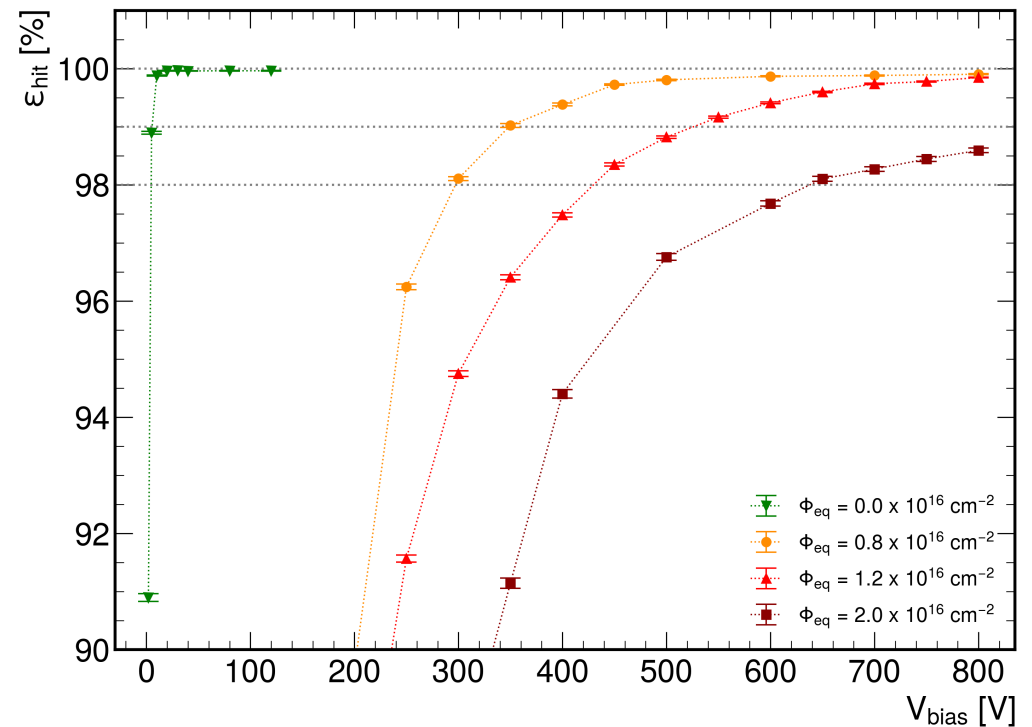


Leakage Current of HPK 25 μm x 100 μm RD53A sensors

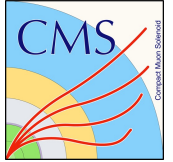
Non irradiated sensor Leakage current final requirement:

$$I_{Bias} < 0.75 \mu\text{A}/\text{cm}^2 \text{ at } V_{fd} +50\text{V}$$

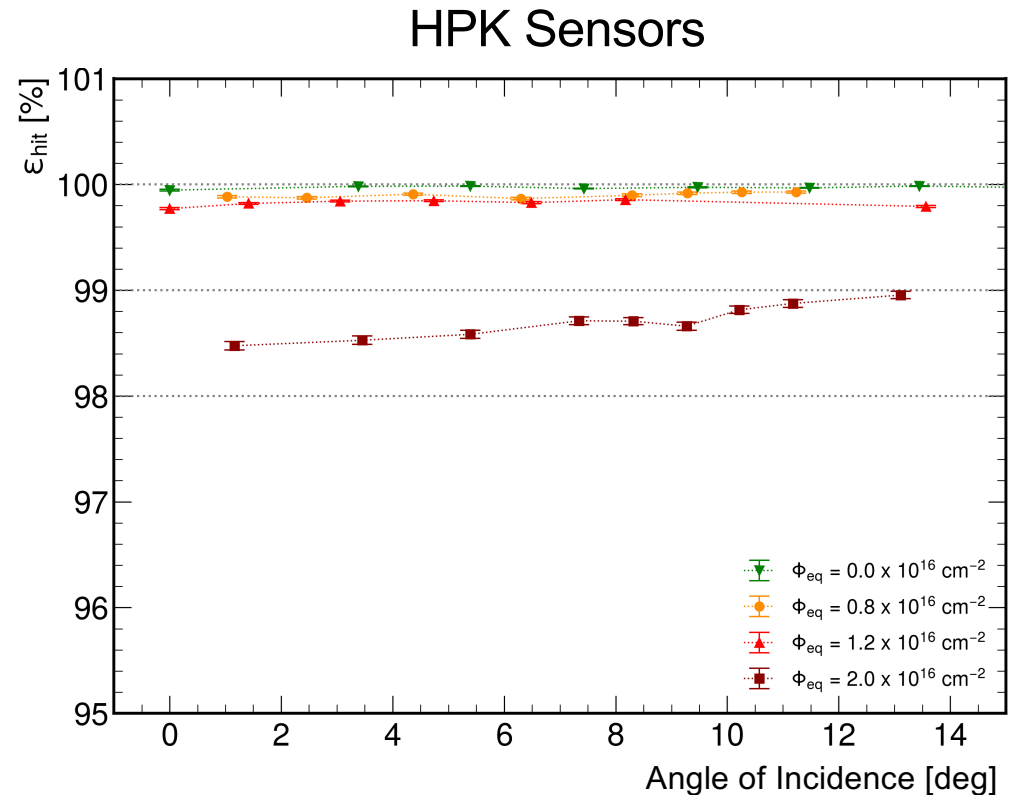
- Non-irradiated
 - Online threshold ~ 1300 e, $+25$ °C
 - $\epsilon_{\text{hit}} > 99\%$ at $V_{\text{bias}} > 5$ V ✓
- $\Phi_{\text{eq}} = 0.8 \times 10^{16} \text{ cm}^{-2}$
 - Online threshold ~ 1400 e, -25 °C
 - $\epsilon_{\text{hit}} > 99\%$ at $V_{\text{bias}} > 350$ V ✓
- $\Phi_{\text{eq}} = 1.2 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{\text{hit}} > 98\%$ at $V_{\text{bias}} > 450$ V ✓
 - $\epsilon_{\text{hit}} > 99\%$ at $V_{\text{bias}} > 550$ V ✓
- $\Phi_{\text{eq}} = 2.0 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{\text{hit}} > 98\%$ at $V_{\text{bias}} > 650$ V ✓



Hit Efficiency vs. Angle of Incidence



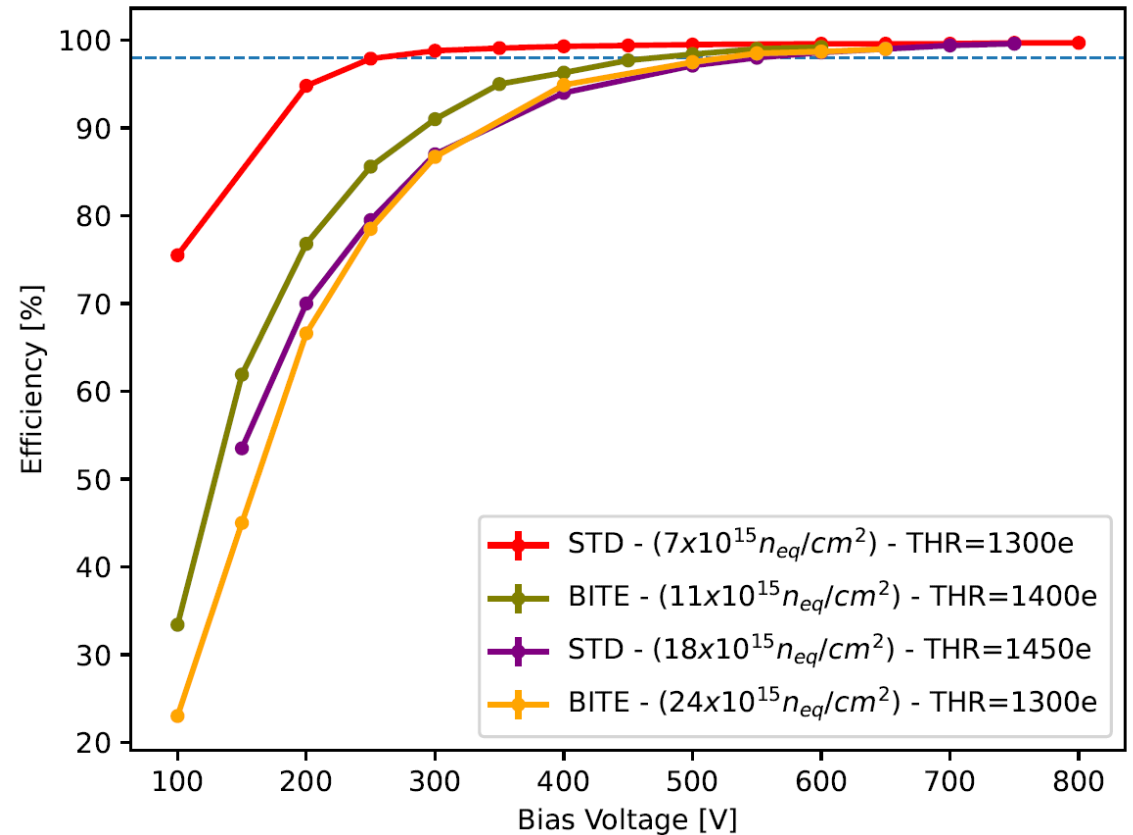
- Non-irradiated
 - Online threshold ~ 1300 e, $+25$ °C
 - $\epsilon_{\text{hit}} > 99\%$ at $V_{\text{bias}} > 5$ V ✓
- $\Phi_{\text{eq}} = 0.8 \times 10^{16}$ cm $^{-2}$
 - Online threshold ~ 1400 e, -25 °C
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 - $\epsilon_{\text{hit}} > 99\%$ at $V_{\text{bias}} > 550$ V ✓
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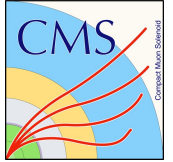
Hit Efficiency – FBK Sensors



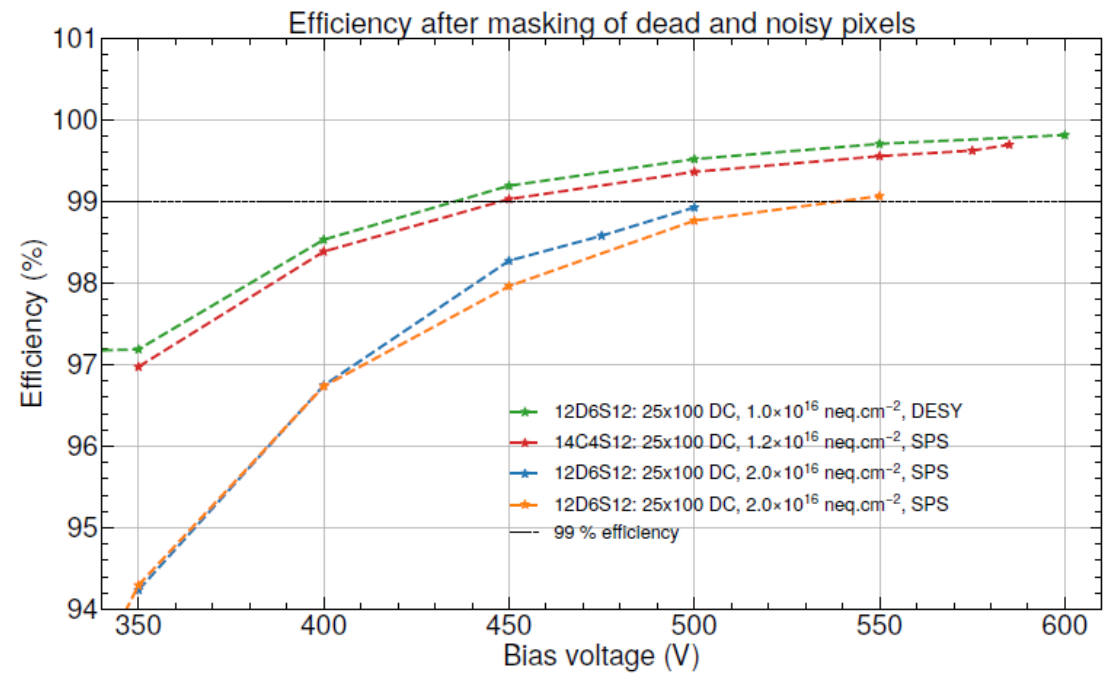
- $\Phi_{eq} = 0.7 \times 10^{16} \text{ cm}^{-2}$
 - Online threshold $\sim 1300 \text{ e}$, $-25 \text{ }^\circ\text{C}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 250 \text{ V}$ ✓
- $\Phi_{eq} = 1.1 \times 10^{16} \text{ cm}^{-2}$
 - Online threshold $\sim 1400 \text{ e}$, $-25 \text{ }^\circ\text{C}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 450 \text{ V}$ ✓
- $\Phi_{eq} = 1.8 \times 10^{16} \text{ cm}^{-2}$
 - Online threshold $\sim 1450 \text{ e}$, $-25 \text{ }^\circ\text{C}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 550 \text{ V}$ ✓
- $\Phi_{eq} = 2.4 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 550 \text{ V}$ ✓



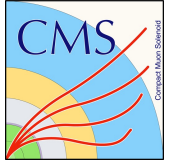
Hit Efficiency – LFoundry Sensors



- $\Phi_{eq} = 1.0 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 450 \text{ V}$ ✓
- $\Phi_{eq} = 1.2 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 450 \text{ V}$ ✓
- $\Phi_{eq} = 2.0 \times 10^{16} \text{ cm}^{-2}$
 - $\epsilon_{hit} > 99\%$ at $V_{bias} > 550 \text{ V}$ ✓

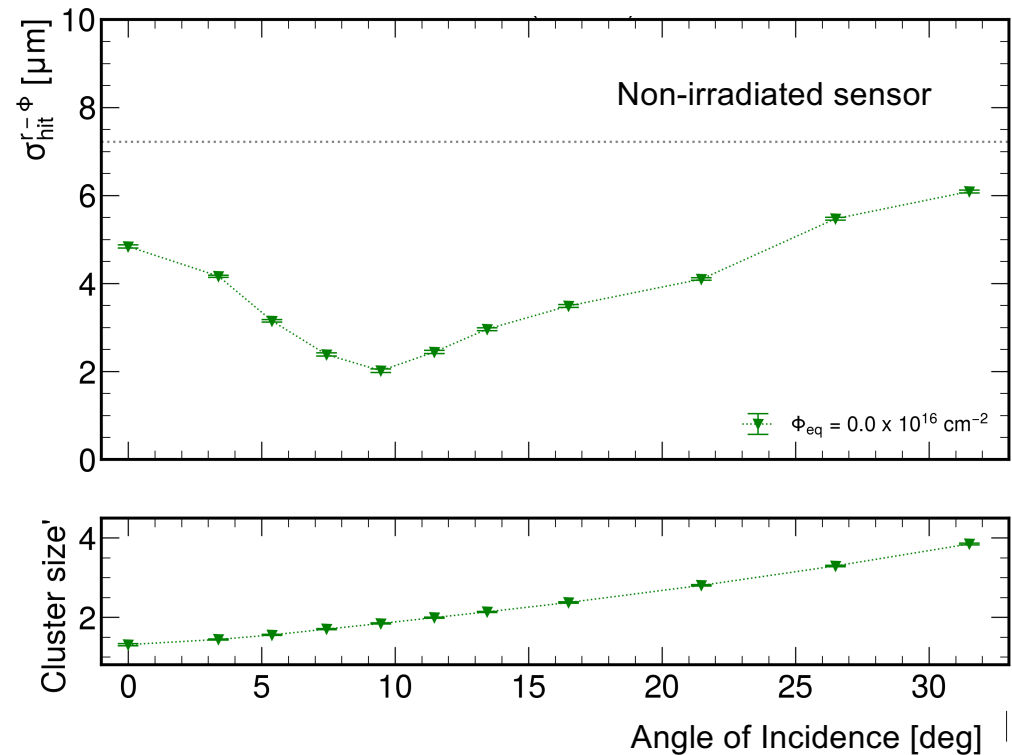


Single Hit Spatial Resolution - HPK

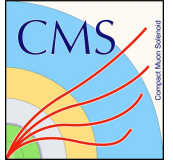


- Non-irradiated at optimal angle:
 - Online threshold ~ 1300 e, $+25$ °C
 - $\sigma_{\text{hit}} \sim 2$ μm at $V_{\text{bias}} = 120$ V ✓
- $\Phi_{\text{eq}} = 0.8 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 7.2$ μm at $V_{\text{bias}} = 600$ V ✓
- $\Phi_{\text{eq}} = 1.2 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 7.2$ μm at $V_{\text{bias}} = 800$ V ✓
- $\Phi_{\text{eq}} = 2.0 \times 10^{16}$ cm^{-2}
 - $\sigma_{\text{hit}} < 7.2$ μm at $V_{\text{bias}} = 800$ V ✓

Rotation around the long pixel axis for charge sharing in the **25 μm** direction

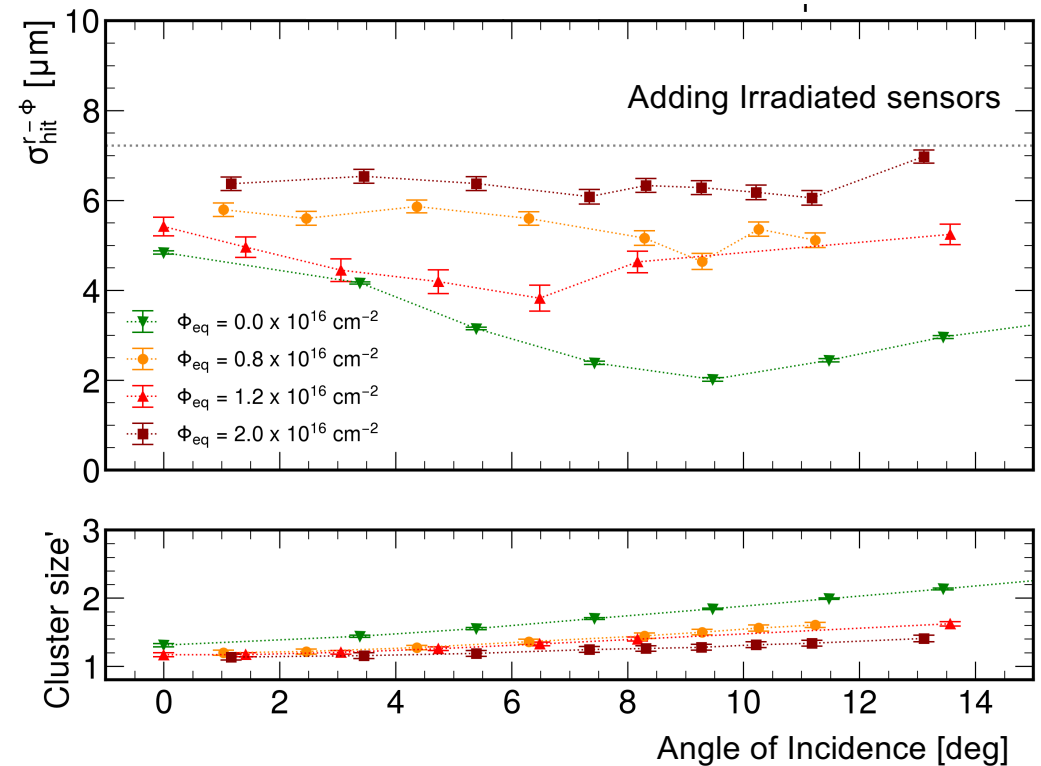


Single Hit Spatial Resolution - HPK

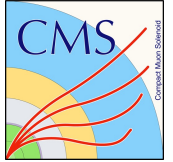


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Rotation around the long pixel axis for charge sharing in the **25 μm** direction

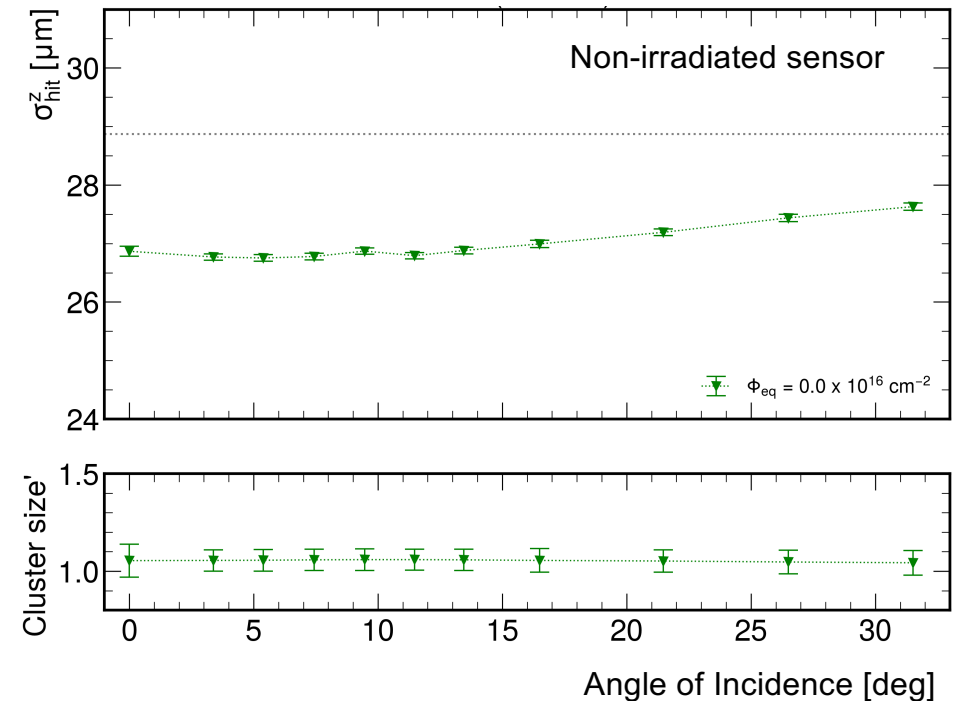


Single Hit Spatial Resolution - HPK

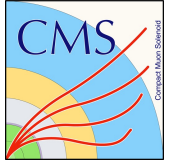


- Non-irradiated at optimal angle:
 - Online threshold ~ 1300 e, $+25$ °C
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 120$ V ✓
- $\Phi_{\text{eq}} = 0.8 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 28.9$ μm at $V_{\text{bias}} = 600$ V ✓
- $\Phi_{\text{eq}} = 1.2 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 800$ V ✓
- $\Phi_{\text{eq}} = 2.0 \times 10^{16}$ cm^{-2}
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 800$ V ✓

Rotation around the short pixel axis for charge sharing
in the **100 μm** direction

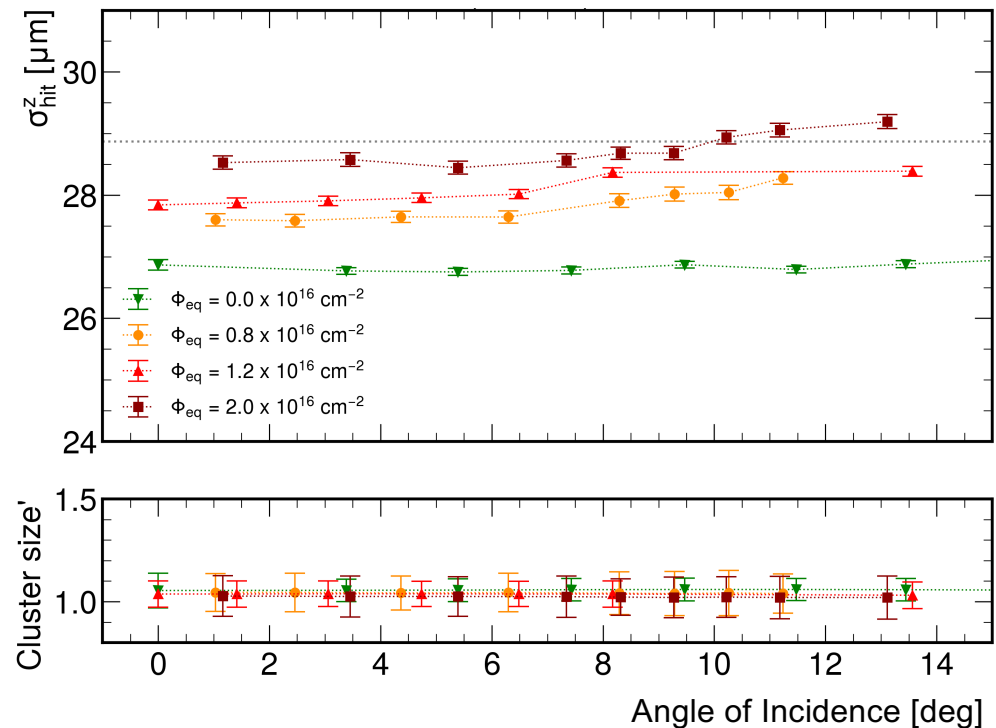


Single Hit Spatial Resolution - HPK



- Non-irradiated at optimal angle:
 - Online threshold ~ 1300 e, $+25$ °C
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 120$ V ✓
- $\Phi_{\text{eq}} = 0.8 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 600$ V ✓
- $\Phi_{\text{eq}} = 1.2 \times 10^{16}$ cm^{-2}
 - Online threshold ~ 1400 e, -25 °C
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 800$ V ✓
- $\Phi_{\text{eq}} = 2.0 \times 10^{16}$ cm^{-2}
 - $\sigma_{\text{hit}} < 28,9$ μm at $V_{\text{bias}} = 800$ V ✓

Rotation around the short pixel axis for charge sharing in the **100 μm** direction



Conclusions and Outlook



- Planar Pixel Sensors produced by FBK, HPK and LFoundry have been characterized in a common effort by the CMS Tracker Collaboration
- Very good electrical behaviour before and after irradiation
- Hit efficiency of $\sim 99\%$ for modules irradiated up to $2.4 \times 10^{16} \text{ n}_{\text{eq}} \text{ cm}^{-2}$
- Hit resolution in r - ϕ ($25 \mu\text{m}$) and z ($100 \mu\text{m}$) better than binary resolution even after irradiation to the highest fluence
- **Sensors from all 3 vendors are qualified for the high-luminosity upgrade of the CMS pixel detector**
- Prototype S.C. Modules with CROC_v1 (CMS chip with final pixel matrix) are being tested as reported in Anna Macchiolo's talk
- First CROC quad full modules of 15.5cm^2 area are being assembled